IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF:

Hideki TAKAHASHI

: EXAMINER: To be Assigned

SERIAL NO: New Application

FILED: Herewith

: GROUP ART UNIT: To be Assigned

FOR: INSULATED GATE SEMI-

CONDUCTOR DEVICE AND MANU-FACTURING METHOD THEREOF

PRELIMINARY AMENDMENT

ASSISTANT COMMISSIONER FOR PATENTS WASHINGTON, D.C. 20231

SIR:

Prior to examination on the merits, please amend the above-identified application, as follows, without prejudice:

Please cancel Claims 1,21, without prejudice or disclaimer.

Please add new Claims 22-39, as follows:

22. (New) An insulated gate semiconductor device, comprising:

a first semiconductor layer of a first conductivity type having first and second main

surfaces on opposite sides thereof;

a second semiconductor layer of a second conductivity type provided on said first

main surface of said first semiconductor layer;